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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/523,735	03/13/2000	Yasuyuki Unno	684.2700CIP	7033
5514 7.	590 02/28/2002			
	03/13/2000 Yasuyuki Unno 0 02/28/2002 CCELLA HARPER & SCINTO JER PLAZA	& SCINTO	EXAMINER	
30 ROCKEFEI NEW YORK, 1			KIM, PE	ETER B
			ART UNIT	PAPER NUMBER
			2851	
			DATE MAILED: 02/28/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

<u></u>		Application No.	plicant(s)				
· Office Action Summary			,				
		09/523,735	UNNO, YASUYUKI				
		Examiner Peter B Kim	Art Unit				
T	h MAILING DATE of this communication ap		2851 correspond nc address				
Period for F	•	,					
THE MA - Extension after SIX - If the peri - If NO per - Failure to - Any reply	TENED STATUTORY PERIOD FOR REPLILING DATE OF THIS COMMUNICATION. Is of time may be available under the provisions of 37 CFR 1. (6) MONTHS from the mailing date of this communication. od for reply specified above is less than thirty (30) days, a rejudy for reply is specified above, the maximum statutory period reply within the set or extended period for reply will, by statut received by the Office later than three months after the mailing term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be to oly within the statutory minimum of thirty (30) da I will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDON	imely filed bys will be considered timely. In the malling date of this communication. ED (35 U.S.C. § 133).				
1)[] R	esponsive to communication(s) filed on 08	January 2002 .					
2a)⊠ T	his action is FINAL . 2b) T	his action is non-final.					
	ince this application is in condition for allow						
C Disposition	losed in accordance with the practice unde of Claims	г <i>Ex рапе Quayle</i> , 1935 C.D. 11,	453 U.G. 213.				
4) Claim(s) 11-29 is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
	5) Claim(s) is/are allowed.						
-	6)⊠ Claim(s) <u>11-29</u> is/are rejected.						
·	7) Claim(s) is/are objected to.						
8)☐ CI Application	aim(s) are subject to restriction and/ Papers	or election requirement.					
9)☐ The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action.							
12)☐ The oath or declaration is objected to by the Examiner.							
Priority under 35 U.S.C. §§ 119 and 120							
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)⊠	All b)☐ Some * c)☐ None of:						
1.]							
2.	2. Certified copies of the priority documents have been received in Application No. 09/123,443.						
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).							
	The translation of the foreign language particularly for domesting the complexity of the transition of						
Attachment(s)	•	. , ,					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Interview Summary (PTO-413) Paper No(s). 5) Notice of Informal Patent Application (PTO-152) 6) Other:							

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DETAILED ACTION

Applicant's arguments filed on Jan. 8, 2002 (Paper #8) have been fully considered.

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 11-13 are rejected under 35 U.S.C. 102(b) as being anticipated by Moslehi (5,040,896).

Moslehi discloses in the abstract and Figure 2, a projection optical system with a plurality of optical elements and correcting means for correcting birefringence of the optical elements. Moslehi discloses in the abstract the method of compensating the birefringence by opposite and equal changes in the other optical elements.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made

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5. Claims 14 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Moslehi in view of Tatsuno et al. (Tatsuno).

Moslehi discloses the claimed invention as discussed above, however, Moslehi does not disclose the use of a diffraction grating to produce form birefringence. Tatsuno discloses in column 1, line 61 through column 5, 38, the use of a diffraction grating on the surface of the optical element to produce birefringence and correct aberration.

Although, Tatsuno does not explicitly state that the period of grating is not greater than the wavelength of the light, it is well known in the art that in order to obtain diffractive light of only zero-th order, the period has to be no greater than the wavelength.

Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to provide the diffraction grating to Moslehi in view of Tatsuno in order to provide birefringence and correct aberration.

6. Claims 16 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Moslehi in view of Sutton et al. (Sutton).

Moslehi discloses the claimed invention as disclosed above, however, Moslehi does not disclose the use of a predetermined stress distribution to produce form birefringence. As indicated by Sutton in column 1, line 49 through column 3, line 63, it is well known in the art that a predetermined stress distribution in an optical element is also an effective means of producing form birefringence. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to provide the stress distribution in the optical elements to Moslehi in view of Sutton in order to provide form birefringence and correct aberration.

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7. Claims 18-21 and 26-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim et al. (Kim) (6,057,970) in view of Moslehi.

Kim discloses in Figure 3 and column 4, a projection exposure apparatus of scanning type with an illumination system and a projection optical system with a birefringent member (200). Although Kim does not disclose explicitly the slit-like light and the speed ratio, such features are well known features of a scanner. However, Kim does not disclose the birefringence correcting element for correcting birefringence of the projection optical system. Moslehi discloses in the abstract and Figure 2, a projection optical system with a plurality of optical elements and correcting means for correcting birefringence of the optical elements. Moslehi discloses in the abstract the method of compensating the birefringence by opposite and equal changes in the other optical elements. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to provide the correcting element of the Moslehi to the invention of Kim in order to obtain wafer with a high resolution.

8. Claims 22, 23 and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim in view of Moslehi as applied to claim 18 above, and further in view of Tatsuno et al. (Tatsuno).

The further difference between the claimed invention and the modified Kim is the use of a diffraction grating to produce form birefringence. Tatsuno discloses in column 1, line 61 through column 5, 38, the use of a diffraction grating on the surface of the optical element to produce birefringence and correct aberration. Although, Tatsuno does not explicitly state that the period of grating is not greater than the wavelength of the light, it is well known in the art that in order to obtain diffractive light of only zero-th order, the period has to be no greater than the wavelength. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made

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to provide the diffraction grating to Kim in view of Tatsuno in order to provide birefringence and correct aberration.

9. Claims 24, 25 and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim in view of Moslehi as applied to claim 1 above, and further in view of Sutton et al. (Sutton).

The further difference between the claimed invention and the modified Kim is the use of a predetermined stress distribution to produce form birefringence. As indicated by Sutton in column 1, line 49 through column 3, line 63, it is well known in the art that a predetermined stress distribution in an optical element is also an effective means of producing form birefringence. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to provide the stress distribution in the optical elements to Kim in view of Sutton in order to provide form birefringence and correct aberration.

Remarks

10. Applicant argues that Moslehi does not disclose the method of correcting birefringence as disclosed in the claimed invention, but the abstract of Moslehi indicates that Moslehi discloses the method of compensating the birefringence by opposite and equal changes in the other optical elements.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE

MONTHS from the mailing date of this action. In the event a first reply is filed within

TWO MONTHS of the mailing date of this final action and the advisory action is not

mailed until after the end of the THREE-MONTH shortened statutory period, then the

shortened statutory period will expire on the date the advisory action is mailed, and any

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the date of this final action.

12. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Peter Kim whose telephone number is (703) 305-0105.

The examiner can normally be reached on Monday-Thursday from 6:30 AM to 4:00 PM.

The examiner can also be reached on alternate Fridays during the same hours.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Russ Adams, can be reached on (703) 308-2847. Any inquiry of a general

nature or relating to the status of this application or proceeding should be directed to the

Group receptionist whose telephone number is (703) 308-0956.

PRK

02/21/02

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